| | Applicant(s) | Application No. | |
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| | CHEN ET AL. | 10/033,408 | |
| | Art Unit | Examiner | Notice of Alleita 6-114. |
| | 1765 | Shamim Ahmed | |
| uded Je course, THIS | s application. If not include ation will be mailed in due | OR REMAINS) CLOSED in the or other appropriate communice. GHTS. This application is sub | The MAILING DATE of this communication appear claims being allowable, PROSECUTION ON THE MERITS IS (C ewith (or previously mailed), a Notice of Allowance (PTOL-85) o TICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIG the Office or upon petition by the applicant. See 37 CFR 1.313 a |
| | | | ☐ This communication is responsive to 10/31/03. |
| | | | ∑ The allowed claim(s) is/are 1-7 and 9-55. |
| | | he Examiner. | \boxtimes The drawings filed on <u>26 December 2001</u> are accepted by th |
| | ı. | | Acknowledgment is made of a claim for foreign priority und |
| | | 3 · · · · · · · · · · · · · · · · · · · | a) ☐ All b) ☐ Some* c) ☐ None of the: |
| | | been received. | 1. Certified copies of the priority documents have b |
| | o | been received in Application N | 2. Certified copies of the priority documents have b |
| cation from the | | | 3. Copies of the certified copies of the priority docu |
| | | | International Bureau (PCT Rule 17.2(a)). |
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| ce a specific | ovisional application) sinc | der 35 U.S.C. § 119(e) (to a pi ion or in an Application Data S | Acknowledgment is made of a claim for domestic priority und reference was included in the first sentence of the specification |
| 1.4 | angan tang beragasak di | plication has been received. der 35 U.S.C. §§ 120 and/or 1 | (a) ☐ The translation of the foreign language provisional app ☐ Acknowledgment is made of a claim for domestic priority und in the first sentence of the specification or in an Application D |
| quirements noted | y complying with the requ | his communication to file a repairs application. THIS THREE | licant has THREE MONTHS FROM THE "MAILING DATE" of thow. Failure to timely comply will result in ABANDONMENT of this |
| NOTICE OF | IER'S AMENDMENT or National IER'S AMENDMENT or N | ted. Note the attached EXAMI reason(s) why the oath or de | A SUBSTITUTE OATH OR DECLARATION must be submitted INFORMAL PATENT APPLICATION (PTO-152) which gives |
| | TO-948) attached | | ☐ CORRECTED DRAWINGS (as "replacement sheets") must be the line of Draftspersor (a) ☐ including changes required by the Notice of Draftspersor 1) ☐ hereto or 2) ☐ to Paper No |
| Examiner | s been approved by the F | rrection filed which ha | (b) ☐ including changes required by the proposed drawing con |
| r No | ne Office action of Paper I | Amendment / Comment or in | (c) including changes required by the attached Examiner's A |
| ne back) of | awings in the front (not the I21(d). | 4(c)) should be written on the demargin according to 37 CFR 1 | dentifying indicia such as the application number (see 37 CFR 1.84 each sheet. Replacement sheet(s) should be labeled as such in the |
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| O-152) | Patent Application (PTO | 5☐ Notice of Informa | Notice of References Cited (PTO-892) |
| • | | | Notice of Draftperson's Patent Drawing Review (PTO-948) |
| | | | Information Disclosure Statements (PTO-1449 or PTO/SB/08), Paper No |
| wance | ment of Reasons for Allow | 8⊠ Examiner's State 9⊡ Other | Examiner's Comment Regarding Requirement for Deposit of Biological Material |
| NORTON XAMINER | NADINE G. N PRIMARY EX | | |
| O' D DWa | I21(d). AL must be submitted. I MATERIAL. I Patent Application (PTO ry (PTO-413), Paper No.dment/Comment ment of Reasons for Allow NADINE G. N | e margin according to 37 CFR 1 It of BIOLOGICAL MATER! E DEPOSIT OF BIOLOGICAL 5☐ Notice of Informa 6☐ Interview Summ 7☐ Examiner's Ame | DEPOSIT OF and/or INFORMATION about the deposit ched Examiner's comment regarding REQUIREMENT FOR THE chement(s) Notice of References Cited (PTO-892) Notice of Draftperson's Patent Drawing Review (PTO-948) Information Disclosure Statements (PTO-1449 or PTO/SB/08), Paper No Examiner's Comment Regarding Requirement for Deposit |

Application/Control Number: 10/033,408

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REASONS FOR ALLOWANCE

1. The following is an examiner's statement of reasons for allowance: the prior art does not teach or suggest a method of growing self-assembled nanowires on the etchable layer by forming an interfacial plane with significant lattice mismatch along all the crystallographic axes except one major axis during q process of forming nanowires as the context of claim 1.

The prior art also does not teach or suggest that the etching rate of the etchable layer is at least twice than that of the self-assembled nanowires as the context of claim 21.

The prior art also does not teach or suggest that the etching or removal rate of the self-assembled nanowires is at least twice than that of etchable layer during the selective removal of the nanowires as the context of claim 39.

2. The closest prior art Choi et al (6,440,637) disclose a step of anisotropic reactive ion etching of the etchable layer using the nano structure as a mask to form the nanowires (37a and 37b) onto a substrate and Choi et al also teach that the self-assembled nano structures (28a and 28b) are removed after forming the nanowires on the substrate (col.6, lines 19-28 and lines 25-26).

However, Choi et al fail to teach the etching rate of the etchable layer is twice than that of the nano structures or vise versa.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably Art Unit: 1765

accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Oath/Declaration

3. The supplemental oath or declaration filed 10/31/03 is acknowledged and recorded in the application. Accordingly, the objection to the oath or declaration by the examiner is withdrawn.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Shamim Ahmed whose telephone number is (571) 272-1457. The examiner can normally be reached on M-Thu (7:00-5:30) Every Friday Off.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nadine G Norton can be reached on (571) 272-1465. The fax phone number for the organization where this application or proceeding is assigned is (703) 872-9306.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0661.

Shamim Ahmed Examiner Art Unit 1765

SA January 10, 2004

SUPERVISOR
NADINE G. NORTON
PRIMARY EXAMINER
Mod Mork